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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|-----------------------|------------------------|----------------------|-------------------------|------------------|
| 10/622,454 | 07/21/2003 | Hiroaki Furuya | 240510US2TTC | 5246 |
| 22850 | 7590 06/05/2006 | | EXAMINER | |
| • | PIVAK, MCCLELLAND, | AHMED, SHAMIM | | |
| 1940 DUKE ALEXANDI | STREET NA, VA 22314 | | ART UNIT PAPER NUMBER | |
| , | | | 1765 | |
| | | | DATE MAILED: 06/05/2006 | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | | | | i v | | | |
|--|--|---|--|-----|--|--|--|
| | | Application No. | Applicant(s) | | | | |
| Office Action Summary | | 10/622,454 | FURUYA, HIROAKI | | | | |
| | | Examiner | Art Unit | | | | |
| | | Shamim Ahmed | 1765 | | | | |
| Period fo | The MAILING DATE of this communication app or Reply | ears on the cover sheet with the o | correspondence address | | | | |
| WHIC - Exte after - If NC - Failu Any | ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Poperiod for reply is specified above, the maximum statutory period vere to reply within the set or extended period for reply with | ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tir will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE | N. mely filed the mailing date of this communication ED (35 U.S.C. § 133). | | | | |
| Status | | | | | | | |
| 1)⊠ | Responsive to communication(s) filed on 23 M | arch 2006. | | | | | |
| · · · · | | action is non-final. | | | | | |
| 3) | Since this application is in condition for allowance except for formal matters, prosecution as to the merits is | | | | | | |
| | closed in accordance with the practice under E | x parte Quayle, 1935 C.D. 11, 4 | 53 O.G. 213. | | | | |
| Disposit | ion of Claims | | | | | | |
| 4)⊠ | Claim(s) <u>1-4</u> is/are pending in the application. | | | | | | |
| | 4a) Of the above claim(s) <u>4</u> is/are withdrawn from consideration. | | | | | | |
| 5) | 5) Claim(s) is/are allowed. | | | | | | |
| - | ☑ Claim(s) <u>1-3</u> is/are rejected. | | | | | | |
| · — | Claim(s) is/are objected to. | | | | | | |
| 8)[_] | Claim(s) are subject to restriction and/o | r election requirement. | | | | | |
| Applicat | ion Papers | | | | | | |
| 9)[| The specification is objected to by the Examine | r. | | | | | |
| 10)⊠ | 10)⊠ The drawing(s) filed on <u>21 July 2003</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner. | | | | | | |
| | Applicant may not request that any objection to the | • | • • | | | | |
| 441 | Replacement drawing sheet(s) including the correct | - · · | • | d). | | | |
| | The oath or declaration is objected to by the Ex | aminer. Note the attached Office | Action or form PTO-152. | | | | |
| Priority (| under 35 U.S.C. § 119 | | | | | | |
| | 12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)⊠ All b)□ Some * c)□ None of: | | | | | | |
| , | 1.⊠ Certified copies of the priority documents have been received. | | | | | | |
| | 2. Certified copies of the priority documents have been received in Application No | | | | | | |
| | 3. Copies of the certified copies of the prior | rity documents have been receive | ed in this National Stage | | | | |
| | application from the International Bureau | | | | | | |
| * (| See the attached detailed Office action for a list | of the certified copies not receive | ed. | | | | |
| | | | | | | | |
| Attachmen | • • | . □ | (DTO 440) | | | | |
| 2) Notic | e of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) | 4) Interview Summary Paper No(s)/Mail D | | | | | |
| 3) 🔲 Infon | mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) or No(s)/Mail Date | 5) Notice of Informal F 6) Other: | Patent Application (PTO-152) | | | | |

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DETAILED ACTION

Election/Restrictions

1. Claim 4 is withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in the reply filed on 3/23/06.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-3 are rejected under 35 U.S.C. 103(a) as being unpatentable over Spierings et al (6,045,715) in view of Chen et al (5,087,481).

Spierings et al disclose a process of chemically etching a glass substrate, which is used for liquid crystal display (LCP) device, which reads on claimed glass substrate and the term "used for" is considered to be an intended use of the glass substrate (abstract).

Spierings et al teach that the glass substrate is flattened (less rough surface) by removing pits or cracks under different circumstances such as stronger etchant and weaker etchant can be used with two different etching rates (col.3, lines 10-col.4, lines 30).

Spierings et al may do not explicitly teach that the chemical treatment is performed by using two sequential steps namely first and second etching with first and second solution.

However, Spierings et al teach that the substrate can be etched for long period of time for reducing the depth of the crack (col.3, lines 59-60), which illustrates the claimed first and second etching solution because as the etching progresses the strength of the etchant will drop over time and that considered to be the second etchant as claimed. Since, the claim is not specifically limit that the two etchant are materially different, it is the examiner's position that both the first and second etchant are the same etchant with different etching rate.

Additionally, Chen et al teach a glass texturing process including the step of preetching step, which resemble the claimed first etching for removing microcracks or scratches prior to a chemical texturing step (col.3, lines 10-31 and abstract).

Therefore, it would have been obvious to one of ordinary skilled in the art at the time of claimed invention to combine Chen et al's teach of pre-etching into Spierings et al's process for effectively removing microcracks for the glass substrate as taught by Chen et al.

Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Kurachi et a (6,913,702) teach a glass substrate treating process with treating agent having different removal capacity; Marshall (5,681,636) teaches

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additional etching steps including lighter etching of glass substrate for forming modified textured glass substrate.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (571) 272-1457. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G. Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Shamim Ahmed Primary Examiner Art Unit 1765

Sa June 1, 2006